

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Keith J. Machia, et al.

Examiner: Unassigned

Serial No: Unassigned

Art Unit: Unassigned

Filed: Herewith

Docket: BUR920010164US2 (15016A)

For: METHOD OF PHOTOLITHOGRAPHIC
EXPOSURE DOSE CONTROL AS A
FUNCTION OF RESIST SENSITIVITY

Date: October 23, 2003

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

PRELIMINARY AMENDMENT

Sir:

In connection with filing the above-identified application under 37 C.F.R. §1.53(b), applicants submit the following amendments and remarks for consideration by the Examiner and entry of record in the above-identified patent application.

CERTIFICATE OF MAILING BY "EXPRESS MAIL"

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I hereby certify that this correspondence is being deposited with the United States Postal Service "Express Mail Post Office to Addressee" service under 37 C.F.R. §1.10 on the date indicated above and is addressed to the Commissioner of Patents and Trademarks, P.O. Box 1450, Alexandria, VA 22313-1450.

Dated: October 23, 2003


Steven Fischman